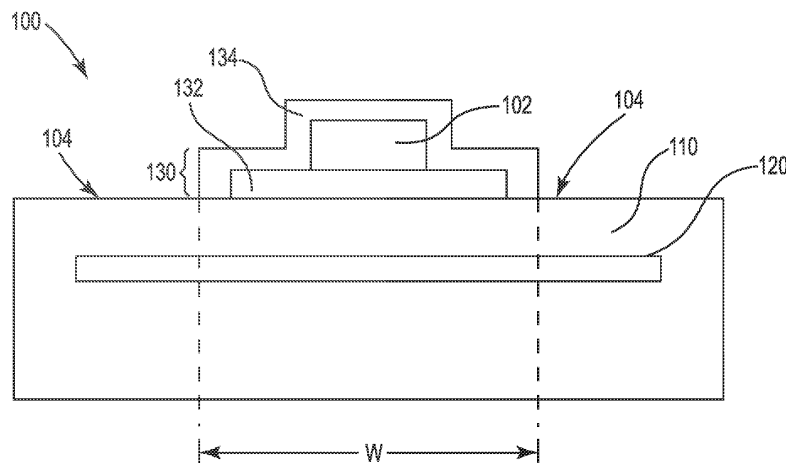




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(54) **Title:** ELECTROSTATIC CHUCK WITH A CHARGE DISSIPATION STRUCUTRE



**Figure 1**

(57) **Abstract:** Described are electrostatic chucks that are useful to support a workpiece during a step of processing the workpiece, the electrostatic chuck including a pattern of charge dissipation lines on an insulating layer, the lines having a first conductive layer and a second conductive layer and being arranged to define enclosed fields of the insulating layer between the lines.

[Continued on next page]

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